

09/28/01

Class	Subclass
ISSUE CLASSIFICATION	

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# U.S. UTILITY Patent Application

**O.J.P.E.**

**PATENT DATE**

SCANNED

TR 3: Q.A. Edh

APPLICATION NO.  
09/964648

CONT/PRIOR  
F

CLASS  
438

**SUBCLASS**  
121

ART UNIT  
2812

**EXAMINER**

C.  $ABR \in R$  ✓

Keiji Yoshimura

## TABLE 1. APPLICANTS

Exposure apparatus, semiconductor device  
manufacturing method,  
exposure apparatus  
maintenance method and semiconductor  
manufacturing factory

PTO-2040  
12/89

## ISSUING CLASSIFICATION

ORIGINAL						CROSS REFERENCE(S)									
CLASS			SUBCLASS			CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)								
INTERNATIONAL CLASSIFICATION															

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<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>	<b>DRAWINGS</b>			<b>CLAIMS ALLOWED</b>	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) (Date)			<b>NOTICE OF ALLOWANCE MAILED</b>  _____	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____ _____	_____ (Primary Examiner) (Date)			<b>ISSUE FEE</b>	
				Amount Due	Date Paid
<input type="checkbox"/> The terminal ____months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) (Date)			<b>ISSUE BATCH NUMBER</b>  _____	
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Form **PTO-436A**  
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